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Docket No.: 8733.475.00-US
(PATENT)

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of:
Dong G. Kim, et al.

Application No.: 09/893,557

Group Art Unit: 2871

Filed: June 29, 2001

Examiner: Z. Qi

For: REFLECTIVE AND TRANSFLECTIVE
LIQUID CRYSTAL DISPLAY DEVICE AND
ITS MANUFACTURING METHOD

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AMENDMENT

Box Non-Fee Amendment
Commissioner for Patents
Washington, DC 20231

Dear Sir:

In response to the Office Action dated October 4, 2002 (Paper No. 12), please amend the above-identified U.S. patent application as follows:

In the Specification

Please amend the specification as follows:

On page 4, paragraph beginning on line 11;

At this time, on the entire surface of the substrate including the gate line 102, the gate electrode 102a and the capacitor lower electrode 102c is the gate insulation film 103 of silicon nitride (SiN_x) film to insulate upper and lower layers, and an semiconductor layer 104 of an island form between the gate insulation film 103 and the source/drain electrodes 105a and 105b. On the entire surface of the substrate including the data line 105, the source/drain electrodes 105a and 105b and the capacitor upper electrode 105c is a passivation film 106 coated in a prescribed thickness.